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Application Number	10/617,843					
Filing Date	July 11, 2003					
First Named Inventor	Saxler					
Group Art Unit	2823					
Examiner Name	Fernando L. Toledo					
Attorney Docket Number	5308-248					

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Examiner Initials*	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited	Date of Publication of Cited						
		Number	Kind Code (if known)	- Document	Document MM-DD-YYYY						

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Examiner Signature Date Considered 9/16/09

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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